

New year with a new journal!



Technology and Language is a new peer-reviewed, open-access, professionally produced online journal.

It invites interdisciplinary explorations at the interface of technology and language. The launch issue will appear in December 2020 with programmatic contributions from philosophy of technology, linguistics, engineering, education, cultural and museum studies, history of technology, art history, literature and theatre studies.

The chief scientific editor of the journal Professor Alfred Nordmann presents the journal (subtitles in Russian and English are available)

